Proceedings of the CSMAG'07 Conference, Košice, July 9–12, 2007

The Electronic Structure and Specific Heat of YNi₄Si

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The studies of the electronic structure and the specific heat of YNi₄Si are reported. Below the Fermi energy $(E_{\rm F})$ the density of states contains mainly the 3d states of Ni, which hybridized with 4d states of Y and 3p states of Si. The theoretical electronic specific heat coefficient $(12.32~{\rm mJ/(mol~K^2)})$ obtained for equilibrium lattice parameters and the experimental value $(13~{\rm mJ/(mol~K^2)})$ are in a reasonable agreement.

PACS numbers: 71.20.Be, 71.20.-b, 65.40.-b

1. Introduction

In recent years ternary compounds RNi₄Si, containing the rare-earth metal (R), have been intensively studied [1–3]. These compounds have a variety of interesting properties such as a mixed-valence state of the Ce ion, a Kondo-like resistivity impurity in CeNi₄Si as well as a strong Mott-type scattering in resistance in YbNi₄Si [2, 3]. From the electronic structure point of view these compounds are of special interest due to the nearly filled Ni(3d) band implying that the Ni magnetic moment is negligible [1]. The YNi₄Si compound is indeed useful considered as the isostructural non-magnetic reference material. Therefore, it is important to characterize its ground-state properties such as electronic structure from ab initio method and specific-heat experiments, which give information on magnetic properties and energy level distribution. The YNi₄Si belongs to a wide

class of compounds which crystallise in the hexagonal $CaCu_5$ structure (space group P6/mmm). In the $CaCu_5$ structure the Ni atoms occupy the crystallographic sites (2c) and (3g), while the rare-earth atoms are located in (1a) and Si atoms occupy (3g) sites.

2. Experimental details and calculation method

The electronic structure was calculated by using the tight-binding linear muffin-tin orbital (TB LMTO) method in the atomic sphere approximation (ASA) [4]. Details of calculation were the same as that for CeNi₄Si [1]. The sample preparation procedure for YNi₄Si is similar to that for CeNi₄Si [1]. The lattice constants are a=4.79 Å and c=4.692 Å (YNi₄Si). Specific heat measurements were performed by PPMS commercial device (Quantum Design) in the temperature range 4–300 K by relaxation method using two- τ model. The error of the measurement was about 2%.

3. Results

The electronic structure calculations for YNi₄Si have shown that its ground state is paramagnetic. The calculated densities of states (DOS) are shown in Fig. 1a. The DOS reflects a large separation of the low-lying bands and the main part of DOS (from -0.497 Ry to $E_{\rm F}$) with respect to the corresponding band widths. Si 3s band is located deeply at the lower part of DOS [-0.73 Ry; -0.58 Ry] below the $E_{\rm F}$. In the upper part of the DOS (above -0.497 Ry) 3d

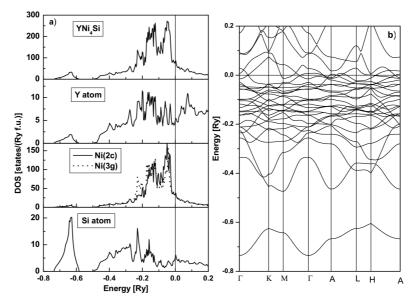


Fig. 1. (a) The calculated DOS for YNi₄Si: the total DOS; the contribution of Y; the contribution of Ni(2c) and Ni(3g); the contribution of Si. (b) The band structure of YNi₄Si along the high symmetry directions.

Ni states overlap with 4d Y states. The hybridization of Si 3p, Y 4d and Ni 3d levels results in continuous DOS from the energy of -0.5 Ry to the Fermi energy. The band structure of YNi₄Si along selected high-symmetry lines within the first Brillouin zone (BZ) is shown in Fig. 1b. The shape of the lowest band is strikingly similar to that of CeNi₄Si [1]. The bottom of the lowest band of YNi₄Si, which consists entirely Si 3s states, has the parabolic shape around the Γ point of high symmetry in the $\Gamma - A$, $\Gamma - M$, $\Gamma - K$ direction (below -0.7 Ry) as well as in the A - H direction (below -0.65 Ry). The group of bands formed between -0.5 Ry and the $E_{\rm F}$ is mainly dominated by Ni 3d states mixed with Si 3p states. $E_{\rm F}$ is crossed in all main directions of the first BZ by the bands. The K, L, Γ , M points of high symmetry bands do not cross $E_{\rm F}$. The DOS at $E_{\rm F}$ is 85.55 [st./(Ry f.u.)] for YNi₄Si. The electronic specific heat coefficient can be estimated from band calculations by using the relation:

$$\gamma = \frac{1}{3}\pi^2 k_{\rm B}^2 N(E_{\rm F})$$
 and is equal to 14.8 mJ/(mol K²). (1)

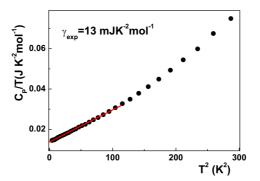


Fig. 2. Specific heat of YNi₄Si, plotted as C_p/T versus T^2 .

The temperature dependence of heat capacity C_p measured for YNi₄Si is presented in Fig. 2. The total heat capacity consists of two contributions: the electronic specific heat $C_{\rm el}$ characterized by the Sommerfield coefficient γ and the phonon contribution $C_{\rm ph}$ which can be expressed as:

$$C_p = C_{\rm el} + C_{\rm ph} = \gamma T + \beta T^3. \tag{2}$$

The Debye temperature is estimated using the relation:

$$\Theta_{\rm D} = \left(\frac{12\pi^4 Rn}{5\beta}\right)^{\frac{1}{3}},\tag{3}$$

where n is a number of atom in the unit cell, R is the gas constant. The experimental values are: $\gamma = 13 \text{ mJ/(mol K}^2)$; $\Theta_D = 388 \text{ K}$. The value of γ obtained from electronic structure for experimental lattice parameters is somewhat higher than the experimental γ . However, minimization procedure of the total energy

of YNi₄Si gives the equilibrium lattice constants of a=4.551 Å, c=4.41 Å and value of $\gamma=12.32$ mJ/(mol K²). Thus, the experimental value and the theoretical value of the electronic specific heat coefficient obtained at equilibrium lattice parameters are in good agreement. Moreover, the theoretical values of γ obtained for YNi₄Si in this work are close to the value of 11.33 mJ/(mol K²) determined for YNi₄B [6] and 13.42 mJ/(mol K²) determined for YNi₄Cu [5].

4. Conclusions

 $Ab\ initio$ calculation has shown that the YNi₄Si is paramagnetic. Below the $E_{\rm F}$ the total DOS contained mainly Ni 3d states in (2c) and (3g) positions hybridized with Y 4d states and Si 3p states which formed the main part of the valence band. The theoretical electronic specific heat coefficient is in good agreement with that obtained from experiments.

Acknowledgments

This work was supported partly by the COST-ECOM P16, by Science and Technology Assistance Agency APVT-51-031704, by VEGA6165; by the contract CE of SAS. J.S. and E.S. are grateful for support of GACR106/06/0368.

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